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Organic Thin Film Transistor Fabricated with Soluble Pentacene Active Channel

Layer and NiOx Electrodes

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Abstract: We report on the fabrication of soluble pentacene-based thin-film transistors (TFTs) that consist of NiOx,

poly-vinyl phenol (PVP), and Ni for the source-drain (S/D) electrodes, gate dielectric, and gate electrode, respectively.

The NiO_x S/D electrodes of which the work function is well matched to that of soluble pentacene are deposited on a

soluble pentacenechannel by sputter deposited of NiO powder and show a moderately low but still effective transmittance

of ~65% in the visible range along with a good sheet resistance of ~40 Ω/\Box . The maximum saturation current of our

soluble pentacene-based TFT is about 15 µA at a gate bias of -40 showing a high field effect mobility of 0.06 cm²/Vs in

the dark, and the on/off current ratio of our TFT is about 10⁴. It is concluded that jointly adopting NiO_x for the S/D

electrodes and PVP for gate dielectric realizes a high-quality soluble pentacene-based TFT.

Key Words: soluble pentacene, NiOx, thin film transistor

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